

<b>Notice of References Cited</b>	Application/Control No. 10/591,785		Applicant(s)/Patent Under Reexamination ABDULLAHI ET AL.	
	Examiner Dave Robertson		Art Unit 2121	Page 1 of 1

#### U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,311,421 A	05-1994	Nomura et al.	700/37
*	B	US-2003/0203106 A1	10-2003	Carnagey et al.	427/213
*	C	US-2004/0162641 A1	08-2004	Suzuki et al.	700/265
*	D	US-6,946,157 B2	09-2005	Folestad et al.	427/2.15
*	E	US-6,945,306 B2	09-2005	Duncan et al.	164/46
*	F	US-6,984,420 B2	01-2006	Suzuki et al.	427/475
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

#### FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

#### NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Sofiane Guessasma, Ghislain Montavon, Christian Coddet, Modeling of the APS plasma spray process using artificial neural networks: basis, requirements and an example, Computational Materials Science, Volume 29, Issue 3, March 2004, Pages 315-333 [retrieved 12/19-2010] from the internet: <a href="http://www.sciencedirect.com/science/article/B6T">http://www.sciencedirect.com/science/article/B6T</a> .
	V	
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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